

Supplementary material

**Electronic and optical properties of core-shell InAlN nanorods: a comparative study  
via LDA, LDA-1/2, mBJ, HSE06,  $G_0W_0$  and BSE methods**

Ronaldo Rodrigues Pela,<sup>1</sup> Ching-Lien Hsiao,<sup>2</sup> Lars Hultman,<sup>2</sup> Jens Birch,<sup>2</sup> and Gueorgui Kostov Gueorguiev<sup>2</sup>

<sup>1</sup>*Supercomputing Department, Zuse Institute Berlin (ZIB), Takustraße 7, 14195 Berlin, Germany<sup>a)</sup>*

<sup>2</sup>*Thin film Physics Division, Department of Physics, Chemistry and Biology (IFM), Linköping University, SE 581 83 Linköping, Sweden*

(Dated: 6 February 2024)

---

<sup>a)</sup>Electronic mail: ronaldo.rodrigues@zib.de

## I. DOS OF INALN NRS

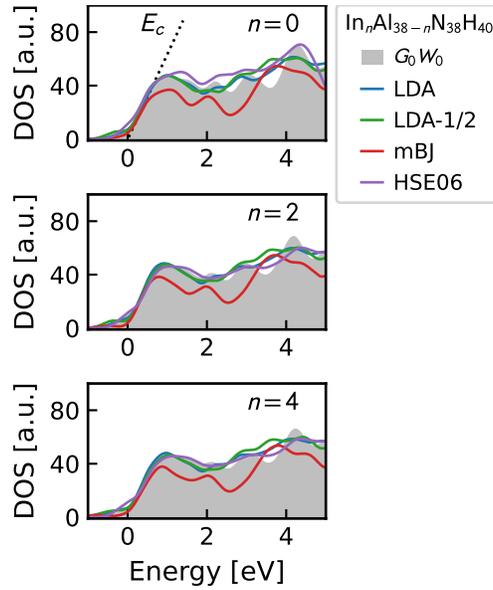


FIG. 1. DOS of passivated core-shell InAlN NRs for different In compositions. All energies are referred to  $E_c$ , the conduction band edge, when states are projected onto core atoms.

### A. Peaks in DOS

TABLE I. Positions (in eV) of peaks  $P_1$ ,  $P_2$ ,  $P_3$  and  $P_4$  in DOS.

	$n = 0$				$n = 2$				$n = 4$			
	$P_1$	$P_2$	$P_3$	$P_4$	$P_1$	$P_2$	$P_3$	$P_4$	$P_1$	$P_2$	$P_3$	$P_4$
$G_0W_0$	-5.00	-0.86	9.59	11.56	-5.22	-1.02	9.37	11.41	-5.44	-1.24	9.25	11.26
LDA	-4.95	-1.19	5.75	8.91	-4.96	-1.13	5.76	8.95	-4.94	-1.10	5.78	8.98
LDA-1/2	-3.78	-0.89	8.30	11.33	-3.84	-1.03	8.22	11.38	-3.99	-1.23	8.10	11.29
mBJ	-4.21	-0.94	7.65	10.48	-4.23	-0.96	7.57	10.48	-4.36	-1.14	7.48	10.38
HSE06	-5.21	-1.14	7.56	10.57	-5.16	-1.04	7.54	10.82	-5.25	-1.13	7.48	10.74

## B. HSE06 and mBJ

HSE06 band gaps for AlN and InN are larger those of mBJ. On the other hand, for AlInN NRs, HSE06 predicts  $\Delta E$  smaller than mBJ. Therefore, to confirm that DOS obtained with HSE06 for the NRs indeed precedes mBJ for conduction states, we performed a DOS calculation for AlN with VASP. The results are given in Fig. 2.

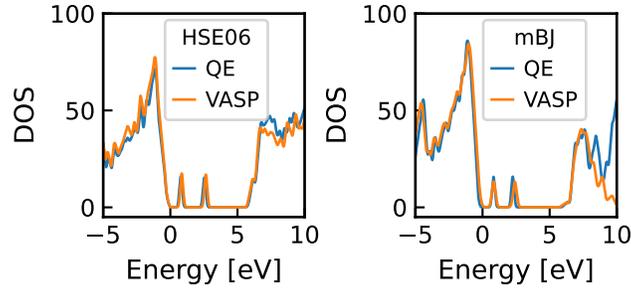


FIG. 2. Comparing the DOS of the AlN NR obtained with Quantum Espresso (QE) and VASP for the functionals: HSE06 (left) and mBJ (right).

## II. OPTICAL PROPERTIES IN THE ENERGY RANGE OF 0-20 eV

### A. AlN and InN

Figure 3 depicts the  $zz$  component of the dielectric function for energies between 0-20 eV.

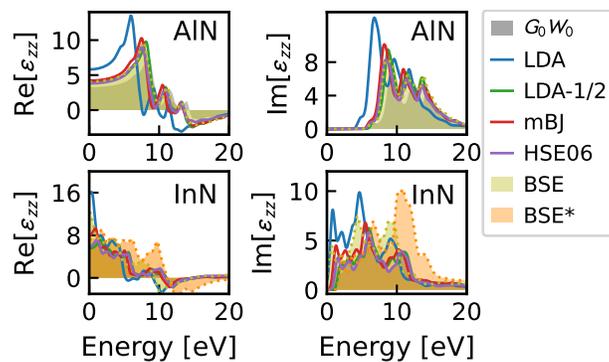


FIG. 3.  $zz$  component of the dielectric function: left, the real part, and right, the imaginary part.

**B. Nanorods**

Figure 3 depicts the  $zz$  component of the dielectric function in the energy range 0-20 eV.

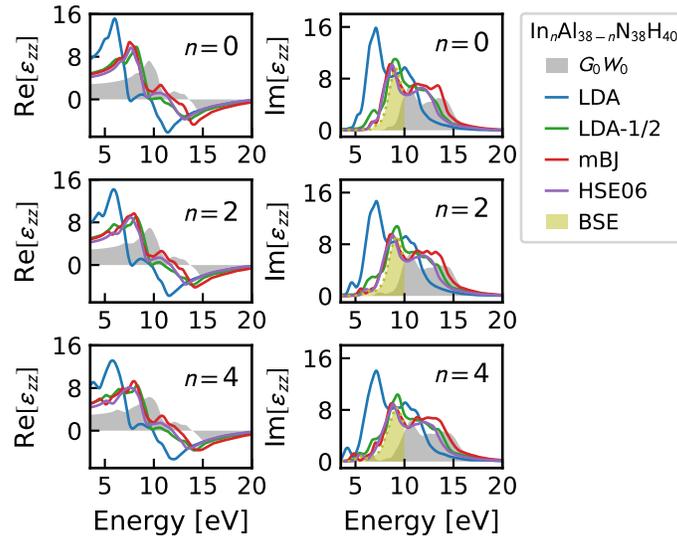


FIG. 4.  $zz$  component of the dielectric function: left, the real part, and right, the imaginary part. The label  $n$  denote the number of In atoms in the NR with chemical formula given by  $\text{In}_n\text{Al}_{38-n}\text{N}_{38}\text{H}_{40}$ .

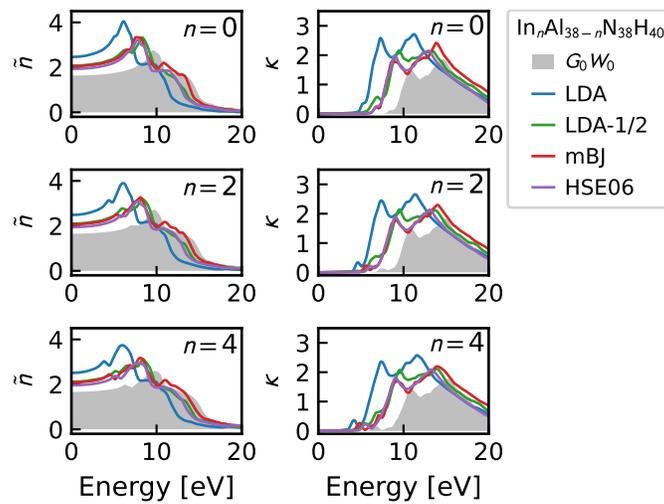
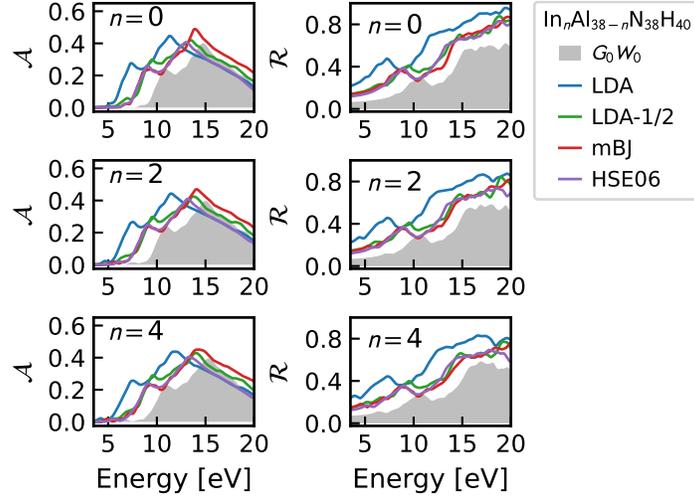


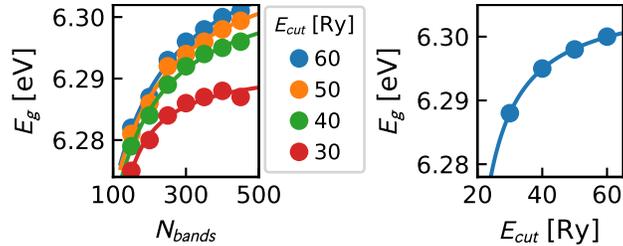
FIG. 5. Refraction index  $\tilde{n}$  and extinction coefficient  $\kappa$ .


 FIG. 6. Absorption  $\mathcal{A}$  and reflectance  $\mathcal{R}$ .

### III. CONVERGENCE BEHAVIOR

#### A. Bulk AlN and InN

Figures 7 and 8 show, for bulk AlN and InN, the convergence behavior of the  $G_0W_0$  band gap. Two parameters are varied: the number of KS states ( $N_{bands}$ ) and the planewave cutoff ( $E_{cut}$ ) used to build the dielectric function. The convergence of  $G_0W_0$  band gap is slower than that


 FIG. 7. AlN band gap obtained with  $G_0W_0$ : convergence behavior with respect to the number of bands (left) and the planewave cutoff for the dielectric function (right).

of DFT. Having a fully converged band gap is challenging, as employing a set of fully converged parameters comes with a very high computational cost. Therefore, we follow here an extrapolation procedure to evaluate the  $G_0W_0$  band gap, adopting the expression<sup>1-3</sup>:

$$E_g(x) = E_g(\infty) + \frac{A}{x+B}, \quad (1)$$

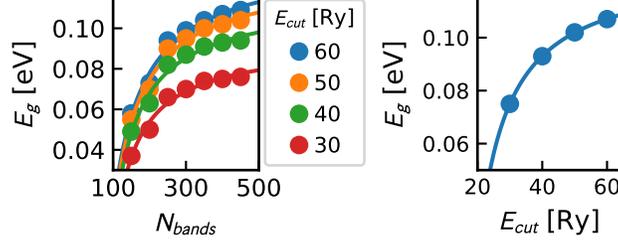


FIG. 8. Same as Fig. 7 for InN.

where  $E_g(\infty)$ ,  $A$  and  $B$  are fit coefficients, and  $x$  is the convergence parameter being tested, which can be  $N_{bands}$  or  $E_{cut}$ . Assuming that the extrapolation with respect to  $E_{cut}$ ,  $N_{bands}$  and the k-grid can be carried out separately, the extrapolated band gap  $E_g^{extr}$  can be evaluated as

$$E_g^{extr} = E_g^{ref} + \delta_{kpt} + \delta_{bands} + \delta_{cut}, \quad (2)$$

where  $E_g^{ref} = E_g(N_{bands}^{ref}, E_{cut}^{ref}, k_{grid}^{ref})$  is the  $G_0W_0$  band gap for a reference calculation employing  $N_{bands}^{ref}$ ,  $E_{cut}^{ref}$ , and  $k_{grid}^{ref}$ . We adopt for AlN:  $N_{bands}^{ref} = 200$ ,  $E_{cut}^{ref} = 40$  Ry; and for InN:  $N_{bands}^{ref} = 400$ ,  $E_{cut}^{ref} = 50$  Ry; and, in both cases,  $k_{grid}^{ref}$  as  $4 \times 4 \times 3$ .

Then  $\delta_{cut}$  and  $\delta_{bands}$  are obtained as

$$\delta_{bands} = E_g(N_{bands} = \infty, E_{cut}^{ref}, k_{grid}^{ref}) - E_g^{ref}, \quad (3)$$

$$\delta_{cut} = E_g(N_{bands}^{ref}, E_{cut} = \infty, k_{grid}^{ref}) - E_g^{ref}, \quad (4)$$

and the contribution of the k-grid to the extrapolation is approximated as<sup>1-3</sup>:

$$\delta_{kpt} = E_g(N_{bands}^{ref}, E_{cut}^{ref}, k_{grid}^{large}) - E_g(N_{bands}^{ref}, E_{cut}^{ref}, k_{grid}^{ref}), \quad (5)$$

where  $8 \times 8 \times 6$  is employed as  $k_{grid}^{large}$ .

Table II collects the relevant data regarding the extrapolation of the  $G_0W_0$  band gap, and, for InN,  $G_0W_0@HSE06$  as well.

## B. Nanorods

### 1. Vacuum

In Eq. (9),  $\Omega$  stands for the volume of the sample. However, in most of *ab initio* codes, including Quantum Espresso,  $\Omega$  is treated as the unit cell volume. For systems with vacuum in

TABLE II. Contributions to the extrapolated  $G_0W_0$  and  $G_0W_0@HSE06$  band gaps. All quantities are given in eV.

	Starting point	$E_g^{ref}$	$\delta_{bands}$	$\delta_{cut}$	$\delta_{kpt}$	$E_g^{extr}$
AIN	LDA	6.28	0.03	0.01	-0.03	6.29
InN	LDA	0.09	0.02	0.03	0.14	0.28
	HSE06	0.64	0.03	0.02	-0.04	0.65

the unit cell, such as the NRs studied here, the dielectric function must be corrected by a factor  $h$  equal to the ratio between the volumes of the cell and the sample. In terms of the geometry shown in Fig. 1, we have for the NRs

$$h = \frac{A_{cell}}{A_{nanorod}} = \frac{4L^2}{3d^2}, \quad (6)$$

where  $A_{cell}$  and  $A_{nanorod}$  are the cross-sections of the unit cell and the NR, respectively.

Denoting  $\epsilon'_{zz}$  as the dielectric function without the correction and  $\epsilon_{zz}$ , the corrected one, then according to Eqs. (9) and (11), it follows that:

$$\text{Im}[\epsilon_{zz}] = h\text{Im}[\epsilon'_{zz}], \quad (7)$$

$$\text{Re}[\epsilon_{zz}] = 1 + h(\text{Re}[\epsilon'_{zz}] - 1). \quad (8)$$

Figure 9 depicts the convergence behavior of the dielectric function with respect to cell dimension  $L$ . These calculations refer to the AIN NR and have been carried out with LDA, and a similar

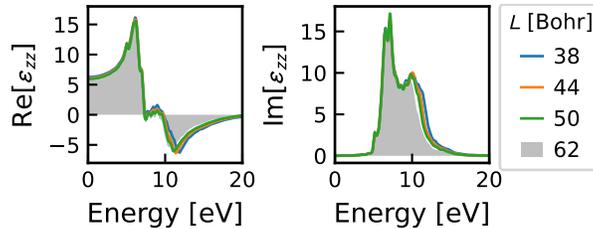


FIG. 9. Convergence behavior of the AIN NR - dielectric function obtained with LDA.

trend has been observed for the other cases. Fig. 9 shows that the size  $L = 44$  Bohr, adopted for the NRs calculations reported in the present work, is sufficient to guarantee satisfactory convergence within the energy range of 0 – 20 eV.

## 2. Band gap

Here, we discuss the precision level expected for our  $G_0W_0$  calculations concerning the NRs. As for bulk AlN and InN, we check convergence with respect to  $N_{bands}$ ,  $E_{cut}$  and the k-grid  $1 \times 1 \times N_{kpt}$ . For the sake of computational cost, we restrict the analysis to the  $\Gamma\Gamma$  band gap and the dielectric function of AlN.

Figure 10 depicts on the left side the impact of  $N_{kpt}$  and  $N_{bands}$  on the  $\Gamma\Gamma$  band gap. Since we adopted  $N_{kpt} = 6$  and  $N_{bands} = 900$ , we estimate, by making the extrapolation procedure as described in III A, a correction of  $\delta_{bands} = -0.06$  eV and  $\delta_{kpt} = -0.08$  eV.

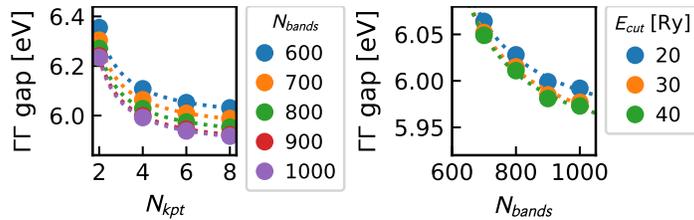


FIG. 10. Convergence behavior of  $\Gamma\Gamma$  band gap obtained with  $G_0W_0$  for the AlN NR: impact of  $N_{bands}$  and  $N_{kpt}$  (left); and  $N_{bands}$  and  $E_{cut}$  (right).

On the right side of Fig. 10, the influence of  $N_{bands}$  and  $E_{cut}$  on the  $\Gamma\Gamma$  band gap is shown. Following the extrapolation procedure, we evaluate a correction of  $\delta_{cut} = -0.03$  eV for the adopted  $E_{cut} = 20$  Ry. Overall, by adding up  $\delta_{bands}$ ,  $\delta_{kpt}$  and  $\delta_{cut}$ , we expect that  $G_0W_0$  band gaps are overestimated by about 0.2 eV.

Figure 11 presents the convergence behaviour of the imaginary part of dielectric function with respect to the vacuum layer (left), the number of bands (middle), and the number of k-points (right). Even though the  $G_0W_0$  band gap requires more strict parameters for convergence, the dielectric function exhibits faster convergence.

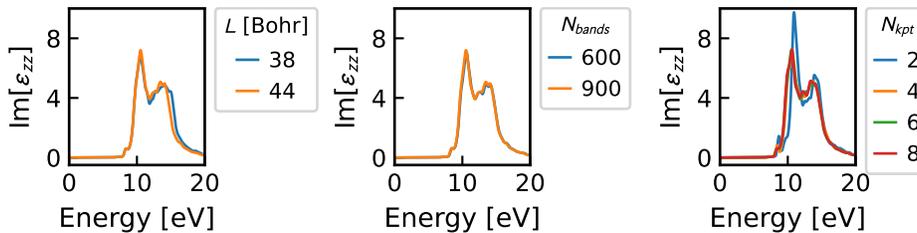


FIG. 11. Impact of the vacuum length, the number of bands, and the number of k-points on the dielectric function of AlN NR.

#### IV. QUANTUM CONFINEMENT AND BAND GAP

The expected band gap enlargement  $\Delta$  due to quantum confinement effects can be estimated by considering a particle of mass  $\mu$  confined inside a circular quantum well of radius  $r$ . Following Ref. 4, we have, in atomic units:

$$\Delta = \frac{a_{(0,0)}^2}{2\mu^*r^2}, \quad (9)$$

where  $a_{(0,0)} = 2.40483$  is the first zero of  $J_0(x)$ , Bessel's function of order zero. To estimate  $\Delta$  for the case of the NRs, we approximate  $\mu$  by the reduced mass of the electron and the heavy hole,  $\mu = (1/m_e + 1/m_{hh})^{-1}$ . Taking the suggested values in Ref. 5:  $m_e = \sqrt[3]{(m_e^\perp)^2 m_e^\parallel} = 0.31$ , in atomic units.  $m_{hh}$  is obtained from the Pikus-Bir parameters given in Ref. 5 as<sup>6</sup>

$$m_{hh} = -\sqrt[3]{(A_2 + A_4)^{-2}(A_1 + A_3)^{-1}}, \quad (10)$$

which gives  $m_{hh} = 1.1$ , in atomic units. Therefore  $\mu = 0.24$ .

Lastly, we consider a range for  $r$  between the radius of the inscribed and the circumscribed circles in the NRs. Taking into account the NR diameter of 14 Å, this implies that  $r$  lies between 6.06 and 7 Å. Applying Eq. (9) gives the range of 1.9-2.5 eV for  $\Delta$ .

#### V. SHIFT IN THE DIELECTRIC FUNCTION

Figure 12 shows, for the NRs,  $\text{Im}[\epsilon_{zz}]$  of the different DFT approaches blue-shifted by  $\delta$  to better match BSE. In the case of  $G_0W_0$ , the dielectric function has been red-shifted. To plot these curves, we shift the vertical transitions in Eq. (9), so that the shifted dielectric function  $\epsilon'_{zz}$  at a given frequency  $\omega$  relates to the original  $\epsilon_{zz}$  by:

$$\text{Im}[\epsilon'_{zz}(\omega)] = \text{Im}[\epsilon_{zz}(\omega - \delta)] \frac{(\omega - \delta)^2}{\omega^2}. \quad (11)$$

It is observed that, setting  $\delta$  to 2.1, 0.1, 0.6 and 0.4 eV for LDA, LDA-1/2, mBJ and HSE06, respectively, leads to an very good agreement with  $\text{Im}[\epsilon_{zz}]$  obtained with BSE.  $G_0W_0$ , on the other hand, can be fitted to BSE with a red shift of 1.4 eV

#### REFERENCES

<sup>1</sup>J. Klimeš, M. Kaltak, and G. Kresse, "Predictive GW calculations using plane waves and pseudopotentials," *Physical Review B* **90**, 075125 (2014).

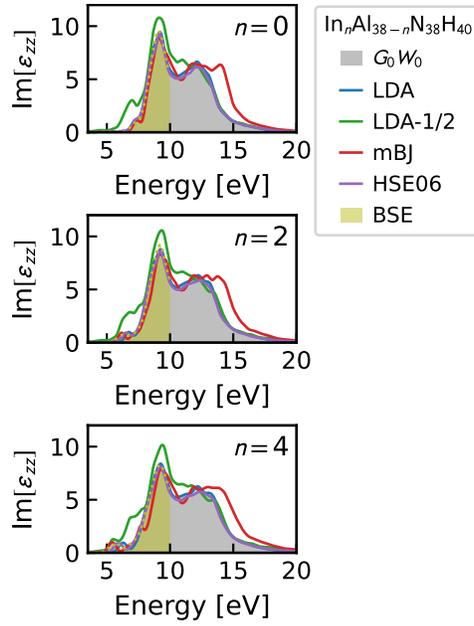


FIG. 12.  $\text{In}_n\text{Al}_{38-n}\text{N}_{38}\text{H}_{40}$  core-shell NRs: Imaginary part of the dielectric function blue-shifted by  $\delta$ . LDA, LDA-1/2, mBJ and HSE06 have been shifted by 2.1, 0.1, 0.6 and 0.4 eV, respectively.  $G_0W_0$  has been red-shifted by 1.4 eV.

<sup>2</sup>D. Nabok, A. Gulans, and C. Draxl, “Accurate all-electron  $G_0W_0$  quasiparticle energies employing the full-potential augmented plane-wave method,” *Physical Review B* **94**, 035118 (2016), 1605.07351.

<sup>3</sup>R. R. Pela, U. Werner, D. Nabok, and C. Draxl, “Probing the LDA-1/2 method as a starting point for  $G_0W_0$  calculations,” *Physical Review B* **94**, 235141 (2016).

<sup>4</sup>R. W. Robinett, “Visualizing the solutions for the circular infinite well in quantum and classical mechanics,” *American Journal of Physics* **64**, 440–446 (1996).

<sup>5</sup>I. Vurgaftman and J. R. Meyer, “Band parameters for nitrogen-containing semiconductors,” *Journal of Applied Physics* **94**, 3675–3696 (2003).

<sup>6</sup>S. L. Chuang and C. S. Chang, “k.p method for strained wurtzite semiconductors,” *Physical Review B* **54**, 2491–2504 (1996).